## Computational and Experimental Studies of the Wide Bandgap Semiconductors NH<sub>4</sub>TiOF<sub>3</sub> and (NH<sub>4</sub>)<sub>2</sub>TiOF<sub>4</sub>

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Figure S1 XRD pattern of the sample prepared by sintering  $NH_4TiOF_3$  at 800 °C for 15 min, compared with standard PDF card (ICDD 86-1156) for anatase.



Figure S2 XPS survey spectra of (a) NH<sub>4</sub>TiOF<sub>3</sub>, (b) (NH<sub>4</sub>)<sub>2</sub>TiOF<sub>4</sub> and (c) TiO<sub>2</sub>.



Figure S3 High-resolution XPS spectra of (a) N 1s (b) O 1s (c) F 1s and (d) Ti 2p.

Table S1 Bond lengths of  $NH_4TiOF_3$  in the experimental data (labelled as single-point calculation) and after the geometry optimisation. Variation ( $\Delta$ ) was calculated referring to the experimental data.

Bond	Single-Point Calculation	Geometry Optimisation	Δ(%)
Ti1-05	1.976	2.196	11.1
	1.901	1.680	-11.6
Ti1-F2	1.801	1.831	1.67
Ti1-F3	1.928	1.977	2.54
	1.906	1.964	3.04
Ti1-F4	1.863	1.938	4.03

Table S2 Bond angle of  $NH_4TiOF_3$  in the experimental data (labelled as single-point calculation) and after the geometry optimisation. Variation ( $\Delta$ ) was calculated referring to the experimental data.

Bond	Single-Point Calculation	Geometry Optimisation	Δ(%)
F2-Ti1-F4	170.2	165.4	-2.82
F3-Ti1-F3	179.3	166.8	-6.97
Ti1-F3-Ti1	163.1	153.8	-5.70
05-Ti1-05	171.7	175.1	1.98
Ti1-05-Ti1	153.8	150.5	-2.15



Figure S4 Structure of  $NH_4TiOF_3$  (a) in the experimental data and (b) after the geometry optimisation.

The Ti-O distances changed from 1.976 and 1.901 to 2.196 and 1.680 after the geometry optimisation, which means the Ti atoms are more off-centred in the  $TiO_2F_4$  octahedra in the ground state, or in other words, the O atoms are more unequally shared by two adjacent  $TiO_2F_4$  octahedra. This led to the changes of the Ti-F distances and the variance of the bond angles F-Ti-F and O-Ti-O.

Table S3 Bond length of  $(NH_4)_2 TiOF_4$  in the experimental data (labelled as single-point calculation) and after the geometry optimisation. Variation ( $\Delta$ ) was calculated referring to the experimental data.

Bond	Single-Point Calculation	Geometry Optimisation	Δ(%)
Ti1-02	1.95	1.91	-1.91
Ti1-F3	1.90	1.90	0.05
Ti1-F4	1.90	1.88	-0.61
Ti5-O6	1.95	1.89	-3.29
Ti5-F7	1.90	1.91	0.55
Ti5-F8	1.89	1.91	0.87

Table S4 Bond angle of  $(NH_4)_2 TiOF_4$  in the experimental data (labelled as single-point calculation) and after the geometry optimisation. Variation ( $\Delta$ ) was calculated referring to the experimental data.

Bond	Single-Point Calculation	Geometry Optimisation	Δ(%)
02-Ti1-02	180	180	0
F3-Ti1-F3	180	180	0
F4-Ti1-F4	180	180	0
Ti1-02-Ti1	149.99	143.77	-4.15
O6-Ti5-O6	180	180	0
F7-Ti5-F7	180	180	0
F8-Ti5-F8	180	180	0
Ti5-O6-Ti5	150.58	149.75	-0.55



Figure S5 Structure of  $(NH_4)_2 TiOF_4$  with label of atoms.



Figure S6 Computed band structures and corresponding PDOS of NH<sub>4</sub>TiOF<sub>3</sub> using different functionals after the single-point energy calculation. (a) PBE-D3, E<sub>Fermi</sub>= -5.35 eV, computed band gap: 2.39 eV; (b) B3LYP-D3, E<sub>Fermi</sub>= -6.21 eV, computed band gap: 3.89 eV.



Figure S7 K-point path in the first Brillouin zone of NH<sub>4</sub>TiOF<sub>3</sub>.



Figure S8 Computed density of states of  $NH_4TiOF_3$  using HSE06-D3 after the geometry optimisation.  $E_{Fermi} = -7.75 \text{ eV}.$ 



Figure S9 COHP of NH₄TiOF₃ over Ti-O (red line) and Ti-F (blue line) bonds, computed after geometry optimisation using HSE06-D3 functional.



Figure S10 Computed band structures and corresponding PDOS of (NH<sub>4</sub>)<sub>2</sub>TiOF<sub>4</sub> using different functionals after the single-point energy calculation. (a) PBE-D3, E<sub>Fermi</sub>= -5.52 eV, computed band gap: 2.98 eV; (b) B3LYP-D3, E<sub>Fermi</sub>= - 6.50 eV, computed band gap: 4.64 eV.



Figure S11 K-point path in the first Brillouin zone of (NH<sub>4</sub>)<sub>2</sub>TiOF<sub>4</sub>.



Figure S12 Computed band structure and density of states of  $(NH_4)_2 TiOF_4$  using HSE06-D3 after the geometry optimisation.



Figure S13 COHP of (NH<sub>4</sub>)<sub>2</sub>TiOF<sub>4</sub> over Ti-O (red line) and Ti-F (blue line) bonds, computed after geometry optimisation using HSE06-D3 functional.



Figure S14 K-point path in the first Brillouin zone of anatase  $\rm TiO_2.$ 



Figure S15 XRD patterns of the immobilised  $NH_4TiOF_3$  sample before and after the photocatalysis test. A sample holder was used for the XRD measurements and the corresponding peaks are provided.  $NH_4TiOF_3$ : CCDC 1880514.

Comple	1 <sup>st</sup> order rate cons	stant (10 <sup>-3</sup> min <sup>-1</sup> )
Sample —	RhB	MB
NH <sub>4</sub> TiOF <sub>3</sub>	9.26±0.02	9.28±0.98
P25	16.9±0.08	21.1±0.17
No catalyst	-0.48±0.01	0.23±0.04

Table S5 Degradation rate constants of the immobilised  $NH_4TiOF_3$ , compared with immobilised P25 and no catalyst.

Table S6 Adsorption efficiency of MB using different photocatalysts.

Sample	Adsorption efficiency of MB (%)
NH <sub>4</sub> TiOF <sub>3</sub>	24.3
P25	2.94
No catalyst	0.76

The adsorption efficiency was calculated by  $(C_{MB} - C_0)/C_{MB}$ , where  $C_{MB}$  is the initial concentration of the tested methylene blue solution and  $C_0$  is the concentration at the light on point, i.e. after the dark adsorption.